

	Type	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L1	2	(dual adj3 purpose) same (electrochemical\$3) same (oxide or oxides) same (conductive)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 14:59
2	BRS	L2	549	(electrochemical\$3) same (reduc\$3) same (oxide\$3) same (conduct\$7)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 15:05
3	BRS	L3	62	2 and (interconnect or interconnects)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 15:06
4	BRS	L4	11908	(dual adj3 (purpose or purposes))	USPAT	2002/10/01 16:11
5	BRS	L5	3	4 same (electrochemically)	USPAT	2002/10/01 16:12
6	BRS	L7	44	(electro adj3 chemical\$3) same reduc\$3 same oxide\$3	USPAT	2002/10/01 16:16
7	BRS	L10	19	7 and copper	USPAT	2002/10/01 16:17
8	BRS	L11	62	(dual adj3 purpose) adj3 (layer or layers or film or films)	USPAT	2002/10/01 16:25
9	BRS	L12	9	11 and (tungsten)	USPAT	2002/10/01 16:25
10	BRS	L13	21	(dual adj3 purpose) same tungsten	USPAT	2002/10/01 16:30
11	BRS	L14	5	13 and (interconnect or interconnects)	USPAT	2002/10/01 16:57
12	BRS	L15	0	dual same tungsten same (interconnect or interconnects) same (electrochemical\$3)	USPAT	2002/10/01 16:58

	Type	L #	Hits	Search Text	DBs	Time Stamp
13	IS&R	L17	1	("6261954").PN.	USPAT	2002/10/01 17:35
14	BRS	L18	20	16 and (electrochemical\$3)	USPAT	2002/10/01 17:40
15	BRS	L19	154	dual same tungsten same (interconnect or interconnects)	USPAT	2002/10/01 17:40
16	BRS	L20	154	dual same tungsten same (interconnect or interconnects)	USPAT	2002/10/01 17:41
17	BRS	L21	5	20 and (electrochemically)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 17:42
18	BRS	L22	519	(electrochemically) same (reduce or reduced or reducing) same (oxide or oxides)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 17:47
19	BRS	L23	232	22 and (tungsten or W)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 17:47
20	BRS	L24	37	22 same (tungsten or W)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 17:50

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21	BRS	L25	10	24 same (surface or surfaces)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 17:55
22	BRS	L26	3	(electrochemical\$10) same (reduce or reduced or reducing) same (oxide or oxides) same (surface or surfaces) same dual	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 17:57
23	BRS	L27	624	(electrochemical\$10) same (reduce or reduced or reducing) same (oxide or oxides) same (surface or surfaces)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 18:06
24	BRS	L28	0	(electrochem\$10) adj10 (oxide or oxides) adj10 (surface or surfaces) adj10 (tungsten or W)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 18:07
25	BRS	L29	252	(electrochem\$10) adj10 (oxide or oxides) adj10 (surface or surfaces)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 18:07

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26	BRS	L30	0	29 and (barrier adj10 tungsten)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 18:08
27	BRS	L31	36	29 and tungsten	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 18:08
28	BRS	L32	467	(voltage or voltages) same (electrochemically or electrochemical) same reducing	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 18:14
29	BRS	L33	1	32 and ((barrier adj10 (tungsten or W)))	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 18:13
30	BRS	L34	153	32 and (tungsten or W)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 18:14

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1	BRS	L1	2	(dual adj3 purpose) same (electrochemical\$3) same (oxide or oxides) same (conductive)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 14:59
2	BRS	L2	549	(electrochemical\$3) same (reduc\$3) same (oxide\$3) same (conduct\$7)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 15:05
3	BRS	L3	62	2 and (interconnect or interconnects)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 15:06
4	BRS	L4	11908	(dual adj3 (purpose or purposes))	USPAT	2002/10/01 16:11
5	BRS	L5	3	4 same (electrochemically)	USPAT	2002/10/01 16:12
6	BRS	L7	44	(electro adj3 chemical\$3) same reduc\$3 same oxide\$3	USPAT	2002/10/01 16:16
7	BRS	L10	19	7 and copper	USPAT	2002/10/01 16:17

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7	BRS	L10	19	7 and copper	USPAT	2002/10/01 16:17
8	BRS	L11	62	(dual adj3 purpose) adj3 (layer or layers or film or films)	USPAT	2002/10/01 16:25
9	BRS	L12	9	11 and (tungsten)	USPAT	2002/10/01 16:25

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22	BRS	L26	3	(electrochemical\$10) same (reduce or reduced or reducing) same (oxide or oxides) same (surface or surfaces) same dual	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 17:57
23	BRS	L27	624	(electrochemical\$10) same (reduce or reduced or reducing) same (oxide or oxides) same (surface or surfaces)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 18:06
24	BRS	L28	0	(electrochem\$10) adj10 (oxide or oxides) adj10 (surface or surfaces) adj10 (tungsten or W)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 18:07
25	BRS	L29	252	(electrochem\$10) adj10 (oxide or oxides) adj10 (surface or surfaces)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 18:07

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	Type	Hits	Search Text
1	BRS	41	(dual adj3 purpose) adj3 layer
2	BRS	5	((dual adj3 purpose) adj3 layer) and (electrochemical or electrochemically)
3	BRS	1	((dual adj3 purpose) adj3 layer) same (tungsten or (tungsten adj nitride) or (tungsten adj3 silicon adj3 nitride))

	DBs	Time Stamp
	USPAT; US-PGPUB;	
1	EPO; JPO; DERWENT; IBM_TDB	2002/10/01 11:43
2	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/01 11:43
3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/01 11:46

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2	BRS	L2	549	(electrochemical\$3) same (reduc\$3) same (oxide\$3) same (conduct\$7)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 15:05
3	BRS	L3	62	2 and (interconnect or interconnects)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM_TD B	2002/10/01 15:06